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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/636,161	08/10/2000	SHUMIN WANG	98124X205487	. 6517
29050 7	590 03/28/2003			
PHYLLIS T. TURNER-BRIM, ESQ., LAW DEPARTMENT			EXAMINER	
870 NORTH C	CABOT MICROELECTRONICS CORPORATION 870 NORTH COMMONS DRIVE		UMEZ ERONINI, LYNETTE T	
AURORA, IL 60504			ART UNIT	PAPER NUMBER
			1765 DATE MAILED: 03/28/2003	2/:

Please find below and/or attached an Office communication concerning this application or proceeding.

		AS-1			
	Application N .	Applicant(s)			
Advisory Action	09/636,161	WANG ET AL.			
·	Examiner	Art Unit			
	Lynette T. Umez-Eronini	1765			
Th MAILING DATE f this communication app	ars on the c ver sheet with the c	correspond nce address			
THE REPLY FILED 13 March 2002 FAILS TO PLACE TO Therefore, further action by the applicant is required to available final rejection under 37 CFR 1.113 may only be either: (1) condition for allowance; (2) a timely filed Notice of Appeal Examination (RCE) in compliance with 37 CFR 1.114.	oid abandonment of this application at the same of the	ation. A proper reply to a			
PERIOD FOR RE	PLY [check either a) or b)]				
a) The period for reply expiresmonths from the mailing	-				
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire is ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).  Extensions of time may be obtained under 37 CFR 1.136(a). The fee have been filed is the date for purposes of determining the period o fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of t (2) as set forth in (b) above, if checked. Any reply received by the Offic timely filed, may reduce any earned patent term adjustment. See 37 C	ater than SIX MONTHS from the mailing FILED WITHIN TWO MONTHS OF THe date on which the petition under 37 CFI fextension and the corresponding amo he shortened statutory period for reply the later than three months after the mail	g date of the final rejection. IE FINAL REJECTION. See MPEP R 1.136(a) and the appropriate extension unt of the fee. The appropriate extension originally set in the final Office action; or			
1. A Notice of Appeal was filed on Appellant's Brief must be filed within the period set forth in 37 CFR 1.192(a), or any extension thereof (37 CFR 1.191(d)), to avoid dismissal of the appeal.					
2. The proposed amendment(s) will not be entered be	ecause:				
(a) They raise new issues that would require furthe	er consideration and/or search (s	see NOTE below);			
(b) ☐ they raise the issue of new matter (see Note below);					
<ul><li>(c)  they are not deemed to place the application in issues for appeal; and/or</li></ul>	better form for appeal by mater	rially reducing or simplifying the			
(d)  they present additional claims without cancelir	ng a corresponding number of fi	nally rejected claims.			
NOTE:		ř.			
3. Applicant's reply has overcome the following rejection	on(s):				
4. Newly proposed or amended claim(s) would local canceling the non-allowable claim(s).	be allowable if submitted in a se	parate, timely filed amendment			
5.⊠ The a) affidavit, b) exhibit, or c) request for application in condition for allowance because:		dered but does NOT place the			
6. The affidavit or exhibit will NOT be considered becaraised by the Examiner in the final rejection.	use it is not directed SOLELY to	o issues which were newly			
7. For purposes of Appeal, the proposed amendment( explanation of how the new or amended claims wo					
The status of the claim(s) is (or will be) as follows:					
Claim(s) allowed: none.					
Claim(s) objected to: 32-35.					
Claim(s) rejected: <u>1-6,8,9 and 16-27</u> .					
Claim(s) withdrawn from consideration: none.					
8. The proposed drawing correction filed on is a	a)☐ approved or b)☐ disappr	oved by the Examiner.			
9. Note the attached Information Disclosure Statement	t(s)( PTO-1449) Paper No(s)	·			
10.⊠ Other: <i>Interview Summary, Paper No. 20</i>					
·					

Continuation of 5. does NOT place the application in condition for allowance because:

Applicant traverses the 103 rejection of claims 1, 3-6, 8, 9, and 16-27 as allegedly obvious over the Sasaki (US 5,770,095) in view of Kaufman (US 5,783,489). Applicant argues that it would not be obvious to substitute Kaufman's diphosphonic acid with Sasaki's phosphonic acids because: Neither of the cited references teaches or suggests Kaufman's phosphonic acids that are used as stabilizers would function as a film-forming agent as disclosed by Sasaki. In view of the functional, structural, and chemical-interaction differences between the phosphonic acids disclosed in Sasaki and Kaufman, one of ordinary skill in the art would not have expected the combination of the two references to succeed.

Applicant's arguments are unpersuasive because Kaufman is relied upon to teach Sasaki's deficiency, "(iii) at least one polishing additive that increases the rate at which the system polishes at least one layer of the substrate, wherein the polishing additive is selected from the group consisting of . . . diphosphonic acids . . ." in the present claim 1. Kaufman teaches, " . . . a variety of optional additives such as . . . stabilizers . . . " (column 6, lines 39-42). "Non limiting examples of preferred stabilizers useful in the CMP slurry of this invention include but are not limited to phosphonic acids such as aminotri(methylenephosphonic) acid and 1-hydroxyethylidene-4diphosphonic acid (column 6, lines 49-55). "The addition of one of more phosphonic acids to the CMP slurry of this invention may also inhibit metallic corrosion (column 7, liens 14-16). Hence the aforementioned are examples of diphosphonic acids as claimed in the present invention. Since Kaufman uses the same diphosphonic acids in a polishing slurry as that of the claimed invention, then using Kaufman's polishing additive in polishing a layer on a substrate would inherently increase the rate at which the system polishes at least one layer of the substrate as claimed in the present invention.

Applicant traverses the reason to combine Sasaki and Kaufman. Applicant argues the Office Action fails to identify any motivation to Sasaki and Kaufman to arrive at the claimed invention.

In response to applicant's argument that there is no suggestion to combine the references, the examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See In re Fine, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988) and In re Jones, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, the reason to combine is for the purpose of promoting stabilization of polishing slurry against settling, flocculating, an and decomposing (Kaufman, column 6, lines 39-42).

> ROBERT KUNEMUND PRIMARY EXAMINER